Solutions for the textbook problems

PS #3

Problem 3.37

Known: Inner and outer radii of a tube wall which is heated electronically at its outer surface and is exposed to a fluid of prescribed hand To. Thermal contact resistance between heater and tube wall and wall inner surface temperature.

Find: Heater power per unit length required to maintain a heater temperature of 25°C

Schematic: $T_0 = 25^{\circ}C$ Schematic: $T_0 = 25^{\circ}C$ Flectrical Heater (9) $T_0 = 75 \text{ mm}$ $T_0 = 75 \text{ mm}$

Assumptions: (1) Steady-State Conditions, (2) One-dimensional Conduction, (3) Constant properties (4) Negligible temperature drop across heater

Analysis: The thermal circuit has the form

Applying an energy balance to a control surface about the heaser.

$$q' = \frac{q'_{a} + q'_{b}}{2\pi k}$$

$$q' = \frac{T_{o} - T_{i}}{\ln(r_{o}/r_{i})} + R'_{t,c} + \frac{T_{o} - T_{\infty}}{(1/h\pi D_{o})}$$

$$q' = \frac{(25-5) c}{\ln(75mm/25mm)} + 0.01 \frac{m_{i}k}{W} + \frac{[25-(-10)] c}{m_{i}^{2}k}$$

$$2\pi \times 16 W_{m.k}$$

$$q' = (728 + 1649) W/m = 2377 W/m$$

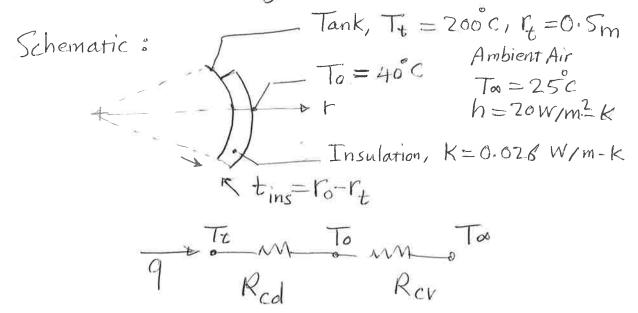
Comments: The conditation, contact and convection resistances are 0.0175, 0.01 and 0.021 m.KAW respectively.

Solution:

Known: Spherical tank of 1-m diameter containing an exothermic reaction and is at 200°C when the ambient is at 25°C. Convection coefficient on outer surface is 20 W/m².K.

Find: Determine the thickness of wrethane foam required to reduce the exterior temperature to 40°C.

Determine the percentage reduction in the heat rate achieved using the insulation.



Assumptions: (1) Steady-State Conditions, (2) One-dimensional, radial (spherical) conduction and (3) Negligible radiation exchange between the insulation outer surface and the ambient surroundings.

Properties: Table A-3, urethane, rigid foam (300K): K=0.026 W/m.K.

(#3)

Analysis: 1a) The heat transfer Situation for the heat rate from the tank can be represented by the thermal circuit shown above. The heat rate from the tank

$$q = \frac{T_t - T_{\infty}}{R_{cd} + R_{cr}}$$

where the thermal resistances associated with conduction within the insulation (Eq. 3.36) and convection for the exterior surface, respectively are

$$R_{cd} = \frac{(1/r_t - 1/r_o)}{47t \, \text{K}} = \frac{(1/0.5 - 1/r_o)}{47t \, \text{K}} = \frac{(1/0.5 - 1/r_o)}{47t \, \text{K}} = \frac{(1/0.5 - 1/r_o)}{6.3267} \, \text{K/W}$$

$$R_{cv} = \frac{1}{hA_s} = \frac{1}{4\pi h r_o^2} = \frac{1}{4\pi t_0^2 \times 10^2}$$

$$= 3.979 \times 10^3 r_o^2 \times 10^3 r$$

To determine the required insulation thickness so that To = 40°C, perform an energy balance on the one o-node.

$$\frac{T_t - T_o}{R_{cd}} + \frac{T_{\infty} - T_o}{R_{cv}} = 0$$

$$\frac{(200-40)K}{(1/0.5-1/r_0)/0.3267 \, K/W} + \frac{(25-40)K}{3.979 \, X10 \, r_0 \, K/W} = 0$$

$$r_0 = 0.5135$$
 $t = r_0 - r_i = (0.5135 - 0.5) = 13.5 mm$

From the rate equation, for the bare and insulated surfaces, respectively.

$$9_0 = \frac{T_t - T_\infty}{1/4\pi h r_t^2} = \frac{(200 - 25)K}{0.01592 \, \text{K/W}} = 10.99 \, \text{KW}$$

$$9_{ins} = \frac{T_t - T_{\infty}}{R_{cd} + R_{cv}} = \frac{(200 - 25)}{(0.161 + 0.01592) K_{IW}} = 0.994 kW$$

Hence, the percentage reduction in heat loss achieved with the insulation is,

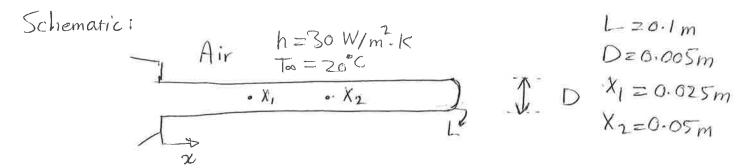
$$\frac{9_{ins}-9_{o}}{9_{o}}\times100=-\frac{0.994-10.99}{10.99}=91\%$$

Problem 3.120

Solution:

Known: Length, diameter, base temperature and mentioner.
environmental conditions associated with a brass rod.

Find: Temperature at specified distances along the rod.



Assumptions: (1) Steady-State Conditions, (2) One-dimensional Conduction, (3) Constant Properties, (4) Negligible radiation, (5) Uniform Convection coefficient h.

Properties: Table A-1 Brass (T=110°C): K=133 W/m.k.

Analoysis: Evaluate the fin parameter

$$m = \left[\frac{hP}{KA_c}\right]^{\frac{1}{2}} = \left[\frac{h\pi D}{K\pi D_{/4}^{2}}\right]^{\frac{1}{2}} = \left[\frac{4h}{KD}\right]^{\frac{1}{2}}$$

$$= \left[\frac{4 \times 30 \text{ W/m}^{2} \cdot \text{K}}{133 \text{ W}_{m,k} \times 0.005 \text{m}}\right]^{\frac{1}{2}} = 13.43 \text{ m}^{\frac{1}{2}}$$

Hence $mL = 13.43 \times 0.1 = 1.34$ and from the results of Example 3.9. It is advisable not to make the infinite rod approximation.

Thus from Table 3.4, the temperature distribution has the form

$$\theta = \frac{\cosh m (L-x) + (h/mk) \sinh m (L-x)}{\cosh m L + (h/mk) \sinh m L}$$

Evaluating the hyperbolic functions, cosh mL = 2.04 and sinh mL = 1.78 and the paramete

$$\frac{h}{mk} = \frac{30 \text{ W/m}^2 \cdot \text{K}}{13.43 (133 \text{ W/m} \cdot \text{K})} = 0.0168$$

with $\theta_b = 180^{\circ}$ the temperature distribution has the form $\theta = \frac{\cosh m(L-\alpha) + 0.0168 \sinh m(L-\alpha)}{2.07}$ (180 C)

The temperatures at the prescribed locations are tabulated below.

$$\frac{X(m)}{X_1 = 0.025} \qquad \frac{Cosh \ m(L-x)}{1.55} \qquad \frac{Sinh \ m(L-x)}{1.19} \qquad \frac{9}{136.5} \qquad \frac{T(°G')}{156.5}$$

$$X_2 = 0.05 \qquad 1.24 \qquad 0.725 \qquad 108.9 \qquad 128.9$$

$$L = 0.10 \qquad 1.00 \qquad 0.00 \qquad 87.0 \qquad 107.0$$

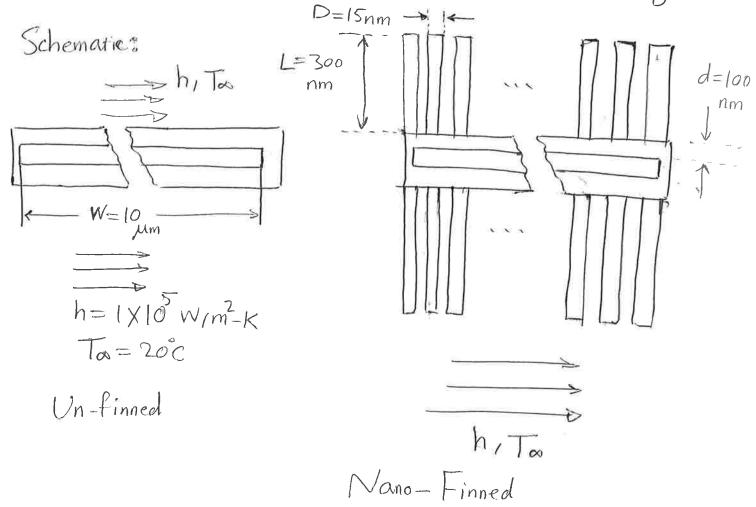
Comments: If the rod were approximated as infinitely long: $T(x_1) = 148.7c., T(x_2) = 112.0c \text{ and } T(L) = 67.6c$ The assumption would therefore result in significant under stimates of the rod temperature.

Problem 3-133

Solution:

Known: Dimensions of electronics package and finned nano-heat Sink. Temperature and heat transfer coefficient of coolant.

Find: Maximum heat tate to maintain temperature below 85°C for finned and un-finned packages.



Assumptions: (1) Steady-state (2) Negligible temperature

Variation across fin thickness, (3) Constant

properties, (4) Uniform heat transfer coefficient

(5) Negligible Contact resistance

(6) Negligible heat loss from edges of package

Properties: Table A.Z., Silicon carbide (Tx 300K): K=490 W, m.k

Analysis: (a) The thermal circuit for the un-finned package is

To Reconv Record Te Record Reconv.

$$q_{12} = \frac{1}{9} q_{12}$$

Where $R_{cond} = \frac{d}{kA} = \frac{100 \times 10^{9} m}{490 \text{ W}} \times (10 \times 10^{6} m)^{2} = 2.04 \text{ K/W}$
 $R_{conv.} = \frac{1}{hA} = \frac{1}{10^{5} \text{W}} \times (10 \times 10^{6} m)^{2} = 1 \times 10^{5} \text{ K/W}$

Thus $q = 2 = \frac{1}{R_{conv} + R_{cond}} = \frac{2(85 - 20)^{\circ} C}{(2.04 + 10^{5}) \text{ K/W}}$

 $= 1.30 \times 10^{-3} \text{W}$

for the finned nano-heat sink, the convection resistance is replaced by a fin array thermal resistance:

(#9)

From Equations 3.103, 3.102 and 3.99.

$$R_{t,o} = \frac{1}{\eta_{h}A_{t}}, \quad \eta_{o} = 1 - \frac{NAp}{At} (1 - \eta_{p}), \quad A_{t} = NA + A_{b}$$

where
$$A_f = \pi D L_c = \pi D (L + D_f) = \pi X 15 \times 10 \text{m} \times (300 + 15) \times 10 \text{m}$$

 $= 1.43 \times 10^{-14} \text{ m}$,
 $A_b = W^2 - N\pi D^2 / 4 = (10 \times 10 \text{m}) - 40,000 \times \pi \times (15 \times 10 \text{m}) / 4$

$$=9.29\times10^{-11}$$
 2 and

$$At = 40,000 \times 1.43 \times 10 \text{ m}^2 + 9.29 \times 10 \text{ m} = 6.65 \times 10 \text{ m}$$

Then with
$$1/2$$
 $mL_c = (4h/kD)^2 L_c = (4x10 \frac{W}{490 \frac{W}{m.k}} / 490 \frac{W}{m.k} \times 15 \times 10 \frac{m}{m}) \times 304 \times 10 \frac{10}{m} = 7.09 \times 10^{-2}$
 $T_c = \frac{tanh(7.09 \times 10^{-2})}{7.09 \times 10^{-2}} = 0.998$

$$\eta_{f} = \frac{\tanh(7.09 \times 10^{2})}{7.09 \times 10^{2}} = 0.998$$

It follows that

$$\eta_0 = 1 - \frac{40,000 \times 1.43 \times 10^{-14} \, \text{m}^2}{6.65 \times 10^{-10} \, \text{m}^2} \left(1 - 0.998\right) = 0.999$$

and
$$R_{t,0} = \frac{1}{0.999 \times 10^5 \text{W} \times 6.65 \times 10^{-10}} = 1.50 \times 10^4 \text{K}$$

 $\frac{4}{\text{W}} \times \frac{4}{\text{W}} \times \frac{4$

Therefore $q = 2 \frac{(T-T_{\odot})}{R_{cond}+R_{1,0}} = 2 \frac{(85c-20c)}{2.04K_{1/W}+1.50\times10^{4}K_{1/W}}$

 $= 8.64 \times 10^{-3} \text{ W}$

Comments: (1) The condition resistance of the silicon

carbide sheets is negligible (2) The fins increas the
allowable heat rate significantly. (3) We have neglected
the contact resistance between the electronics and the
Silicon carbide Sheets. If it dominates, the fins will not
be effective in increasing the allowable heat rate.
Little is known about contact resistance at nanoscale.